	Hits	Search Text	DBs
32	141	((system or apparatus or module) same (expos$4 or irradiat$4 or illuminat$4) same (first or initial) same (alignment or interferometer)) and ((second or double or multiple or subsequent$4 or sequent$4) same (expos$4 or illuminat$4 or irradiat$4) same (apparatus or system or module)) and ((diffract$4 or holographic or interference or (dual$4 near6 beam)) same (expos$4 or illuminat$4 or pattern)) and (line$3width or lines or (line near9 space)) and ((expos$4 or irradiat$4 or illuminat$4) near30 ((unexpos$4 or masked or shielded) near12 (portion or area or line or pattern)))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
33	0	((system or apparatus or module) same (expos$4 or irradiat$4 or illuminat$4) same (first or initial) same (alignment or interferometer)) and ((second or double or multiple or subsequent$4 or sequent$4) same (expos$4 or illuminat$4 or irradiat$4) same (apparatus or system or module)) and ((diffract$4 or holographic or interference or (dual$4 near6 beam)) same (expos$4 or illuminat$4 or pattern)) and (line$3width or lines or (line near9 space)) and ((expos$4 or irradiat$4 or illuminat$4) near30 ((unexpos$4 or masked or shielded) near12 (portion or area or line or pattern)) near29 linewidth)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
34	0	((system or apparatus or module) same (expos$4 or irradiat$4 or illuminat$4) same (first or initial) same (alignment or interferometer)) and ((second or double or multiple or subsequent$4 or sequent$4) same (expos$4 or illuminat$4 or irradiat$4) same (apparatus or system or module)) and ((diffract$4 or holographic or interference or (dual$4 near6 beam)) same (expos$4 or illuminat$4 or pattern)) and (line$3width or lines or (line near9 space)) and (((expos$4 or irradiat$4 or illuminat$4) near30 ((unexpos$4 or masked or shielded) near12 (portion or area or line or pattern))) same linewidth)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
35	10	((system or apparatus or module) same (expos$4 or irradiat$4 or illuminat$4) same (first or initial)) and ((second or double or multiple) same (expos$4 or illuminat$4 or irradiat$4) same (apparatus or system or module)) and ((diffract$4 or holographic or interference) same (expos$4 or illuminat$4 or pattern) same (line$3width or lines)) and (expos$4 same (unexpos$4 or line) same pattern$4 same align$5) and (first near9 linewidth) and ((second or subsequent or sequential$4) near16 linewidth)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
36	1	((system or apparatus or module) same (expos$4 or irradiat$4 or illuminat$4) same (first or initial) same (alignment or interferometer)) and ((second or double or multiple or subsequent$4 or sequent$4) same (expos$4 or illuminat$4 or irradiat$4) same (apparatus or system or module)) and ((diffract$4 or holographic or interference or (dual$4 near6 beam)) same (expos$4 or illuminat$4 or pattern)) and (line$3width or lines or (line near9 space)) and ((expos$4 or irradiat$4 or illuminat$4) near30 ((unexpos$4 or masked or shielded) near12 (portion or area or line or pattern))) and (first near20 linewidth) and (second near20 linewidth)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
37	81	((system or apparatus or module) same (expos$4 or irradiat$4 or illuminat$4) same (first or initial) same (alignment or interferometer)) and ((second or double or multiple or subsequent$4 or sequent$4) same (expos$4 or illuminat$4 or irradiat$4) same (apparatus or system or module) same align$4) and ((diffract$4 or holographic or interference or (dual$4 near6 beam)) same (expos$4 or illuminat$4 or pattern)) and ((line$3width or lines or (line near9 space)) same (first or second)) and ((expos$4 or irradiat$4 or illuminat$4) near30 ((unexpos$4 or masked or shielded) near12 (portion or area or line)))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB